

SPECIFICATION

INK JET HEAD AND A METHOD OF MANUFACTURING THE INK JET HEAD

Field of the Invention

The present invention relates to a recording head of an ink jet recording apparatus of the on-demand type which spouts forth ink droplets toward a recording medium, such as a recording paper, in accordance with a print signal, thereby forming an ink image on the recording paper, and a method of manufacturing the recording head, and more particularly to the construction of a vibrating film which forms one of the walls defining an ink chamber for discharging ink droplets and functions to transfer a vibration from a piezoelectric transducer to the ink chamber.

Background Techniques

An ink jet head of the called on-demand type which spouts forth ink droplets in accordance with a print signal is categorized into two types according to the type of the ink discharging force generating means. The first type of the ink jet head is a called bubble jet type of the ink jet head in which a heater for instantaneously vaporizing ink is located at the nozzle tip, and ink droplets are generated and spouted forth by an expanding pressure when ink is vaporized. The second type of the ink jet head is constructed such that a part of an ink chamber forming an ink reservoir is constructed with a piezoelectric transducer which is deformed

This Sheet Has Been Replaced



- 1 -

REPLACED SHEETS		SG
☒	Description	: paged 1 to paged 21
☒	Claim(s)	: paged 22 to paged 23
☒	Drawing(s)	: paged 24 to paged 25
☒	Abstract	: paged 26 to paged 27
DATE OF RECEIPT		

according to a print signal, and ink droplets are impelled to emit forward by a pressure generated in the ink chamber by the deformation of the piezoelectric transducer.

The on-demand type of the ink jet head as the second type of the ink jet head, as disclosed in Published Unexamined Japanese Patent Application Nos. Sho. 58-119870 and 58-119872, is constructed such that a vibrating film (called a diaphragm in both the publications) forming an ink chamber is coupled with a second end of a piezoelectric transducer fastened at a first end to a base, with an island-like protrusion (called a leg in both the publications) inserted therebetween. The expanding and contracting actions of the piezoelectric transducer cause the piezoelectric transducer to push the leg and to deform the vibrating film. The deformed film causes ink of the ink chamber to forcibly emit forward in the form of ink droplets through a nozzle opening.

Neither of the above-mentioned publications discloses any specific method of forming the vibrating film and the leg. The leg takes a complicated construction where it is fitted into a bearing. Therefore, it is very difficult to accurately manufacture and assemble the leg member and the bearing member for the purposes of size reduction and high density of packaging.

To solve those problems, a first measure taken that is disclosed in Published Unexamined Japanese Patent Application No. Hei. 3-15555 is such that, as



shown in Fig. 10, a vibrating film 61a (called a vibrating plate in the publication) made of silicon, 1.8 μm thick, and an island-like protrusion 61b (called a protrusion in the same publication) made of silicon oxide, 100 μm thick, are coupled together into a vibrating film 61 with a protrusion by the manufacturing technique of semiconductor elements, and the island-like protrusion 61b is brought into contact with a piezoelectric transducer 60.

In another measure taken by the publication, as a second measure, the island-like protrusion 61b is formed on the vibrating film 61a, 1 to 10 μm thick, made of metal, such as nickel, stainless, iron, copper, silver, gold, tantalum, or titanium, by an electroforming method, and the island-like protrusion 61b is brought into contact with the piezoelectric transducer 60.

In yet another measure taken by the publication, as a third measure, the island-like protrusion 61b of which the material and the method are not disclosed is fastened to the vibrating film 61a as an organic material film of 50 μm thick, and the island-like protrusion 61b is brought into contact with the piezoelectric transducer 60.

In a fourth measure taken by Published Unexamined Japanese Patent Application No. Hei. 3-190744, as shown in Fig. 11, a dummy layer, 100 μm thick, is formed on an electrode 71a of a piezoelectric transducer 70, and the resultant structure is cut by dicing process. The



piezoelectric transducer 70 is separated, by the dicing, to form a dummy layer island-like protrusion 73b. A vibrating film 73a (called a cover member in the publication) of approximately 50 μm thick is bonded to the dummy layer island-like protrusion 73b by epoxy adhesive.

To realize a practical ink jet head by any of those conventional techniques, the following problems are created in addition to the difficulty of accurate manufacturing and assembly.

Firstly, the vibrating film 61a, when formed of a high polymer resin of approximately 50 μm thick, cannot transfer pressure and displacement that are high enough to discharge ink, to an ink chamber 64. Even if Pb-zirconate-titanate that is considered, at present, to have the highest transducing efficiency is used for the piezoelectric material of the piezoelectric transducer, the displacement achieved is several μm or less. When a high polymeric resin film ten times or more as thick as the above displacement is used and it is pushed with the piezoelectric transducer, the displacement and pressure by pushing are absorbed by plastic deformation. Accordingly, it is not suitable for the recording head of the small size and high density of packaging. Secondly, the vibrating film formed of a silicon film or a metal foil is not resistive to the bending deformation. It will be fatigued and broken down. Therefore, it is not suitable for the displacement transfer member for the ink jet head which



will repeat the deformation totally several hundreds million times at high speed. Further, those materials are extremely high in rigidity. Because of this, those are not suitable for the materials for the vibrating film which must be flexible as possible.

With the view of solving the above problems, the present invention has an object to realize the structure of an ink jet head which is highly efficiently operable and to manufacture, at low cost, an ink jet head using a vibrating film with a protrusion, which enables the structure to easily be manufactured in a mass production manner.

Disclosure of the Invention

An ink jet head for forcibly discharging ink droplets through nozzle openings in a manner that a pressure of ink within an ink chamber is increased by displacing a vibrating plate constituting a part of the ink chamber by a piezoelectric transducer, in which said vibrating plate is formed of a high polymeric resin thin film and rigid protrusions directly fastened to said high polymeric resin thin film. With such a construction, an expanding/contracting motion of the piezoelectric transducer is efficiently transferred to the ink chamber, enlarging a minute contact area of the piezoelectric transducer and amplifying the pushing force to the ink chamber. Therefore,



an ink jet head reliable and excellent in the ink discharging characteristic is realized.

Brief Description of the Drawings

Fig. 1 is a perspective view showing the structure of an ink jet head to which an embodiment of the present invention is applied.

Fig. 2 is a cross sectional view showing a portion of the ink jet head to which an embodiment of the present invention is applied.

Fig. 3 shows a set of diagrams showing an operation of the ink jet head of the invention.

Fig. 4 is a cross sectional view showing a discharge pressure generating means of the ink jet head to which an embodiment of the present invention is applied.

Fig. 5 is a perspective view, when viewed from the lower side, showing a key portion of the ink jet head to which an embodiment of the present invention is applied.

Fig. 6 is a set of diagrams showing a sequence of steps of a manufacturing process showing an embodiment of the present invention.

Fig. 7 is a set of diagrams of a manufacturing process showing an embodiment of a method of manufacturing the ink jet head of the present invention.



Fig. 8 is a perspective view showing a key portion showing an example of the ink jet head manufactured by the manufacturing method of the invention.

Fig. 9 is a set of diagrams of a manufacturing process showing another embodiment of a method of manufacturing the ink jet head of the present invention.

Fig. 10 is a diagram showing a prior art.

Fig. 11 is a diagram showing another prior art.

Best Modes for Embodying the Invention

The present invention will be described in detail with reference to the accompanying drawings.

In the present embodiment, two lines of nozzles each of 180 dpi (dot/inch) are arrayed so as to realize a printer of 360 dpi in resolution.

Fig. 1 is an exploded perspective view showing an example of an ink jet head to which the present embodiment is applied. As shown in Fig. 1, a mounting hole 11 passing through a head frame 10 supports a base member 5 to be given later in order to position it in X- and Y-axis directions. The top end face of the piezoelectric transducer 1 when longitudinally viewed is bonded to an island-like protrusion 20b as a rigid protruded part of a vibrating film 20 (referred to as an island-having vibrating film) as a vibrating plate with a protrusion, whereby securing the positioning in the Z-axis direction. The island-having



vibrating film 20, a flow path substrate 12, and a plate-like nozzle plate 13 having nozzle openings 13a formed therein are laminated in this order to form a laminated structure.

Fig. 2 is a cross sectional view showing a portion of the ink jet head to which an embodiment of the present invention is applied. An ink chamber 22 is formed of the nozzle plate 13 having nozzle openings 13a formed therein, the flow path substrate 12, and a vibrating film 20a as a high polymeric resin thin film of the island-having vibrating film 20.

An ink reservoir, not shown, an ink supply pipe 14, an ink port 16, and the ink chamber 22 communicate with one another. Ink 6 is supplied from the ink reservoir (see Fig. 1). Reference numeral 23 designates a thick part of the island-having vibrating film, which is formed simultaneously with the island-like protrusion 20b. The piezoelectric transducer 1 is fastened at its base member 5 to the head frame 10 by means of adhesive 90. With such a structure, the principle of discharging ink droplets is as illustrated in Fig. 3. An electrical connection for driving the piezoelectric transducer 1, not shown in Fig. 3, is wired such that a drive signal is input to the transducer through first and second wiring boards 30a and 30b, a base electrode 5a, and first and second transducer electrodes 4a and 14b, as shown in Fig. 2. In a state of Fig. 3A, the piezoelectric transducer 1 is in a standby mode. As shown in Fig. 3B, when



voltage is applied to the piezoelectric transducer 1, it contracts in the direction orthogonal to the nozzle plate 13 (Z-axis direction) , while pulling the island-having vibrating film 20 including the vibrating film 20a and the island-like protrusion 20b. When the electric field is removed, as shown in Fig. 3C, the resilient restoring force of the piezoelectric transducer 1 and the island-having vibrating film 20 increases the pressure of the ink 6 within the ink flow path 22, causing the ink chamber to forcibly discharge ink droplets 6a through the nozzle opening 13a. Then, the piezoelectric transducer 1 is set again in a standby mode.

The island-having vibrating film 20 receives the pushing force generated by the piezoelectric transducer 1 and functions mainly to provide a discharge of the largest possible ink droplet 6a (i.e., the weight or volume of the ink droplet). The largest possible ink droplet 6a can be discharged when the following conditions are satisfied:

- 1) The vibrating film 20a is as flexible as possible.
- 2) An area of the island-like protrusion 20b where it pushes the ink flow path 22 is set large.
- 3) The island-like protrusion 20b is as rigid as possible.



With regard to the condition 1) above, 0.002 mm is the lower limit of the film thickness in reducing the thickness of the vibrating film when considering a leakage of the ink 6 caused by defects of the vibrating film 20a, such as pin holes. If a film of high polymeric resin as a flexible material is used, it can be thinned up to this figure.

With regard to the condition 2), because of the demands for the size reduction and high density packaging of the ink jet head, there is a limit in enlarging the island-like vibrating film 20. To prevent an interference between the adjacent ink flow paths 22, it is necessary to set the area of the vibrating film 20a at a fixed value or more. This is one of the causes of limiting the enlargement of the size of the island-like protrusion 20b.

Therefore, the formation of the island-like protrusion 20b which is rigid as stated in the condition 3), that is, has a high rigidity, and is thick in the displacement direction is the best way to most effectively increase the volume or weight of the ink droplet 6a.

After the tests of many types of trial products, the inventor of the present Patent Application discovered the following fact. When adhesive, for example, is placed between the vibrating film 20a of high polymeric resin and the rigid island-like protrusion 20b, the separation between the vibrating film and the island-like protrusion takes place



at the interface between them, considerably damaging the reliability. Further, because of the thickness of the adhesive, a transfer efficiency of the displacement fluctuates, making it very difficult to control a variation of the characteristics. For this reason, it is advisable to directly fasten to the vibrating film 20a with the island-like protrusion 20b.

Fig. 4 is a cross sectional view showing a discharge pressure generating means of the ink jet head to which an embodiment of the present invention is applied.

The pressure generating means includes the piezoelectric transducer 1 of a multi-layer structure in which a piezoelectric member 2 and conductive members 3a and 3b (referred to as internal electrodes 3a and 3b) are alternately layered. Conductive members 4a and 4b, which are respectively connected to the conductive members 3a and 3b, are further formed on the piezoelectric transducer 1. The first half of the piezoelectric transducer 1, as viewed longitudinally, is bonded to the base member 5, while the end of the second half not bonded is bonded to the island-like protrusion 20b of the island-having vibrating film 20 (see Fig. 2).

The use of the thus constructed longitudinal mode vibrator can generate a higher pressure than the use of the deflection vibrator. Use of the vibrator of the laminated type produces a large displacement at a low voltage applied.



In this embodiment, the piezoelectric transducer is designed to have the following dimensions: the width of each of an array of the piezoelectric transducers when viewed in the array direction is 80 μm ; the pitch of the array of the piezoelectric transducer when viewed in the array direction is 141 μm ; the thickness of the laminated structure when viewed in the lamination direction is approximately 0.5 mm; the lamination pitch in the lamination direction, i.e., the distance between the internal electrodes is approximately 20 μm ; and the laminated structure length in the longitudinal direction is approximately 5 mm. When voltage of about 20 V is applied between the external electrodes 4a and 4b of the piezoelectric transducer thus dimensioned, a displacement of 1 μm and 300,000 Pa. were obtained. As a result, ink of about 0.1 μ gram was discharged.

Fig. 5 is a perspective view, when viewed from the lower side, showing a key portion of the ink jet head to which an embodiment of the present invention is applied.

In the structure, the length (denoted as l1 in Fig. 2) of the ink chamber 22 is 1.5 mm; the height (h1 in Fig. 2) of the ink chamber 22 is 180 μm ; the width of the ink chamber 22 is 100 μm ; the thickness of the vibrating film 20a is 4 μm ; the length (l2 in Fig. 2) of the protrusion 20b is 1.3 mm; the height (h2 in Fig. 2) of the protrusion 20b is 40 μm ; and the width of the protrusion 20b is 30 μm .



A manufacturing method to realize the construction of the present invention will be described.

An embodiment of a first manufacturing process of the invention is illustrated in Figs. 6A through 6I.

A thin film 50 of metal or ceramics, 0.01 to 1mm thick, is prepared. A preferable material is any of copper, nickel, iron, stainless, silicon and the like since it is easy to work as will be seen later (fig. 6A).

A high polymeric resin 20a is coated, 1 to 25 μ m thick, entirely over one of the surfaces of the thin film 50 (Fig. 6B). Any of vacuum film forming process, e.g., vacuum vapor deposition, dip forming, roll coating, spray, and casting methods may be used for the film formation. The high polymeric resin 20a may be any of polyimide (PI) resin, polyether imide (PEI) resin, polyamide-imide (PAI) resin, poly-para-ban acid (PPA) resin, polysulfone (PSF) resin, polyether sulphone (PES) resin, polyether ketone (PEEK) resin, polyphenylene sulfide (PPS) resin, polyolefin (APO) resin, polyethylene-naphthalate (PEN) resin, alaimde resin and the like. The film forming method must be chosen according to the material used. Of those film forming methods, the casting method is preferable because it can easily form a smooth and uniform-thick film.

The high polymeric resin 20a as the vibrating film 20a as referred to above is preferably polyimide resin when considering its useful properties; high resistivity to



etching liquid and resist removal liquid used in the etching process to be given later, high resistivity to the contents of the ink 6, adhesiveness developed by the resin per se, and excellent flexibility useful for the vibration film.

A photo resist 51 is formed on the other surface of the thin film 50 on which the high polymeric resin 20a is not formed (Fig. 6C).

Using a photo mask 52, the formed photo resist 51 is irradiated with ultraviolet rays 53. As a result, the photo resist 51 is selectively exposed to the ultraviolet rays (Figs. 6D and 6E).

Then, the photo resist 51 is developed and exposed portions 51a are left (Fig. 6F).

The thin film 50 is selectively subjected to chemical etching process, using the photo resist 51a. The remaining portions of the thin film 50 are formed as island-like protrusions 20b (Fig. 6G).

Subsequently, while leaving the exposed portions 51a, a island-having vibrating film 20 including island-like protrusions 20b and the high polymeric resin 20a and a thick part (designated by reference numeral 23 in Fig. 2) are formed (Fig. 6H).

Finally, one of the surfaces of the island-having vibrating film 20 is entirely coated with an inorganic film 21 made of metal or ceramics. The inorganic film 21 may be formed on either of the island-having vibrating film 20. It



is formed preferably on the surface of the vibrating film 20a on which the island-like protrusions 20b are formed, when considering the objects to form the inorganic film 21. The first object to form the film is to prevent deterioration of the vibration characteristic of the piezoelectric transducer owing to the penetration of ink ingredients. The second object is to prevent deterioration of the vibrating film 20a owing to the spray of the ink 6 and a size variation of the film by the same cause. A preferable thickness of the inorganic film 21 is preferably 0.1 to 2 μm so as to secure the ink shielding function and the vibration characteristic of the piezoelectric transducer 1 (Fig. 6I). The inorganic film 21 is not always essential to the present invention. A swelling of the vibrating film 20a can be reduced to within a practically tolerable level by a proper choice and optimization of ink used. By hardening the resin film in a state that an internal stress is generated in the coating direction, in the step (b) of the manufacturing process, a state as if the resin film 21 is attached to the thick part 23 while being tensioned is obtained, when it is completed as the island-having vibrating film 20. If so manufactured, an excessive dull is not formed in the vibrating film 20a if a slight swelling is caused in the film by the ink.



A sequence of steps of manufacturing process according to the second embodiment of the present invention is shown in Figs. 7A through 7F.

As shown in Fig. 7A, a plate member 40 is prepared. The plate member 40 becomes first island-like protrusions 16a through a process to be given later.

As shown in Fig. 7B, a precursor of high polymeric resin is laid on one of the surfaces of the plate member 40, and heat or light is applied to it to form a vibrating film 20a.

In the subsequent step of Fig. 7C, a photosensitive resist 41 is formed on the other surface of the plate member 40, and subjected to exposure or development process, thereby forming a desired pattern of the photosensitive resist.

As shown in Fig. 7D, metal to serve as second island-like protrusions 16b is caused to deposit in the windows 42 of the plate member 40 bearing the patterned photosensitive resist 41.

Then, as shown in Fig. 7E, the photosensitive resist 41 is removed.

Finally, as shown in Fig. 7F, the photosensitive resist 41 is removed, windows 43 through which the plate member 40 is exposed are removed by chemical etching process, for example. In the resultant structure, the first island-like protrusions 16a are formed under the second island-like



protrusions 16b. This step completes the island-having vibrating film 20.

As shown in the above-mentioned manufacturing process, the deposited metal (second island-like protrusions 16b) already form part of the island-like protrusions 20b on the plate member 40. Thereafter, the plate member 40 as the lower layer is etched to form the first island-like protrusions 16a, thereby forming the island-having vibrating film 20. Accordingly, it is readily seen that the island-having vibrating film 20 of the large thick can easily be formed.

Fig. 8 is a perspective view showing a key portion showing an example of the ink jet head manufactured by the manufacturing method of the invention. In the figure, there is illustrated an example of an island-having vibrating film 20 manufactured by the manufacturing process of this embodiment. The vibrating film 20a is made of polyimide, 0.005 mm thick. A formation density x of the island-like protrusions 20b is 0.1411 mm corresponding to 180 dpi. The width x_1 of the island-like protrusion 20b is 0.03 mm. The length y thereof is 1.7 mm. With such dimensions, the first island-like protrusions 16a of z_1 thick and the second island-like protrusions 16b of z_2 thick can be formed by a beryllium copper foil of 0.05 mm thick and an electrotyped nickel film of 0.05 mm thick. Accordingly, the island-like protrusions 20b, which is formed by using the member which is



inherently rigid and satisfactorily thick, is little deformed and has a high displacement transfer efficiency.

A sequence of steps of manufacturing process according to the third embodiment of the present invention is shown in Figs. 9A through 9F.

As shown in Fig. 9A, a plate member 9 is prepared. The plate member 9 is made preferably of material of high corrosion proof such as copper, beryllium copper, titanium copper, phosphorus bronze, iron, or iron-nickel alloy.

Then, as shown in Fig. 9B, a first inorganic thin film 121 is formed on one of the surfaces of the plate member 9. The film forming means may be any of the following methods: a vacuum film forming method, such as sputtering, vapor deposition, or CVD (chemical vapor deposition), a dip forming method by the first inorganic thin film 121 in a state of solution, a roll coating method, a spray method, and a plating method of depositing the first inorganic thin film 121. Metal of high sealing performance or ceramics is preferable of the first inorganic thin film 121. Accordingly, the vacuum film forming method or the plating method is preferable for the film forming method. In this embodiment, a film (first inorganic thin film 121) of nickel was formed by the plating method. Gold, chromium, palladium and platinum are available, in addition to the nickel.

The thickness of the first inorganic thin film 121 is preferably 0.0001 to 0.02 mm in order to secure the



dimensional accuracy of the island-like protrusion 20b by etching and to ensure the sealing of the plate member 9 in cooperation with a second inorganic thin film 122.

As shown in Fig. 9C, an elastic film 20a is formed on either of the surfaces on which the first inorganic thin film 121 is formed. The elastic film 20a, as described above, must have an inverse characteristic of that of the island-like protrusion 20b, and be as thin as possible and flexible, in order to efficiently transfer the pushing force of the piezoelectric transducer 1. This embodiment also uses polyimide as in the previous embodiment.

As shown in Figs. 9D and 9E, a photosensitive resist film 9a is formed on the other surface of the plate member 9. It is patterned by the exposure and developing process. In this embodiment, the formation density of the photosensitive resist film 9a is 0.1411 mm pitch corresponding to 180 dpi.

As shown in Fig. 9F, the plate member 9 is selectively removed by such means as chemical etching. Subsequently, the first inorganic thin film 121 is selectively removed similarly by chemical etching, plasma or ion etching process.

In the next step, as shown in Fig. 9G, the photosensitive resist film 9a is removed.

In the final step, as shown in Fig. 9H, a second inorganic thin film 122 is formed on the surface of the island-like protrusions 20b, and the island-like protrusions



20b are sealed in every direction. The best film forming means is a nonelectrolysis plating method which can selectively form only the island-like protrusions 20b. In this embodiment, nickel is used for the second inorganic thin film 122 as for the first inorganic thin film. In addition to nickel, gold, chromium, palladium and platinum are preferable.

The thickness of the second inorganic thin film 122 is preferably 0.0001 mm or more, more preferably 0.02 mm.

Through the process steps, the island-having vibrating film 20 is formed. With such a construction, even if ink ingredients penetrate through the elastic film 20a, for example, the corrosion proof of the island-like protrusion 20b is secured, ensuring the reliability of the ink jet head for a long time. Further, material such as Cu-containing metal that has such a high rigidity as to satisfy the ink discharge performance, and a high corrosiveness and allows a fine work, may be used for the island-like protrusion 20b. Therefore, both the reliability and the ink discharge performance can be satisfactorily secured.

In the ink jet head manufactured according to the construction and the method of the invention, the discharged ink droplet 6a is increased by 15 weight %, and a high efficiency of pushing force transfer is obtained.

As described, the island-having vibrating film is constructed such that the thick island-like protrusion of



high rigidity is directly fastened to the very thin vibrating film of high polymeric resin, improving the ink discharging characteristic. Since such a structure is easily and accurately manufactured, a low cost and a high quality of the resultant head of the ink jet head are achieved.

Further, since an insulating material may be used for the vibrating film 20a, the island-like protrusions, if it is made of metal of high rigidity, can easily be insulated from the drive electrodes exposed to the vibrator surface.

Field of the Invention

As described above, the ink jet head of the present invention is suitable for the image recording machines, such as copying machines, printers and facsimile machines.



CLAIMS

1. An ink jet head for forcibly discharging ink droplets through nozzle openings in a manner that a pressure of ink within an ink chamber is increased by displacing a vibrating plate constituting a part of the ink chamber by a piezoelectric transducer, in which said vibrating plate is formed of a high polymeric resin thin film and rigid protrusions directly fastened to said high polymeric resin thin film.
2. The ink jet head according to claim 1, in which an inorganic thin film is formed on either of the surfaces of said vibrating plate.
3. The ink jet head according to claim 1, in which an inorganic film is formed between the surface of said rigid protrusions and said high polymeric resin thin film.
4. The ink jet head according to claim 1, in which said vibrating plate includes a thick part enclosing said rigid protrusions and is contained in the same layer as of said rigid protrusions, wherein said resin thin film is attached to said thick part while being tensioned.
5. The ink jet head according to claim 1, in which said high polymeric resin thin film is made of polyimide.



6. The ink jet head according to claim 1, in which a major component of said rigid protrusions is any of stainless, nickel, and beryllium copper.

7. The ink jet head according to claim 1, in which said piezoelectric transducer is a piezoelectric vibrator of the vertical vibrating type.

8. The ink jet head according to claim 1, in which said piezoelectric transducer is a piezoelectric vibrator of the laminated type.

9. A method of manufacturing an ink jet head for forcibly discharging ink droplets through nozzle openings in a manner that a pressure of ink within an ink chamber is increased by displacing a protrusion-having vibrating plate constituting a part of the ink chamber by a piezoelectric transducer, in which said vibrating plate includes a one-piece construction of a high polymeric resin film and rigid protrusions formed by the following steps of:

- 1) forming a high polymeric resin film on either of the surfaces of an inorganic thin plate, and
- 2) selectively removing said thin plate.

10. The manufacturing method according to claim 9, further comprising the step of forming an inorganic film on



either of the surfaces of said protrusion-having vibrating plate.

11. The manufacturing method according to claim 9, in which in the process of forming an inorganic film on either of the surfaces of said protrusion-having vibrating plate, an internal stress in the contraction direction is generated in the high polymeric resin.

12. The manufacturing method according to claim 9, in which a major component of said rigid protrusions is either of stainless and nickel.

13. The manufacturing method according to claim 9, in which said high polymeric resin thin film is made of polyimide.

14. A method of manufacturing an ink jet head for forcibly discharging ink droplets through nozzle openings in a manner that a pressure of ink within an ink chamber is increased by displacing a protrusion-having vibrating film constituting a part of the ink chamber by a piezoelectric transducer, in which said vibrating film by

1) a first step of forming a high polymeric resin film on either of the surfaces of a plate member;



2) a second step of selectively depositing second rigid protrusions on the other surface of said plate member; and
3) a third step of selectively removing said plate member and forming first rigid protrusions.

15. The manufacturing method according to claim 14, in which said rigid protrusions contain beryllium copper as a major component.

16. The manufacturing method according to claim 14, in which said high polymeric resin thin film is made of polyimide.

